PTO/SB/08e (03-08)
Approved for use through 04/30/2008 OMB 0651-0031
U.S. Patent and Trademark Office, U.S. DEPARTMENT OF COMMERCE Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number.

	Application Humber	10/00/00	
	Filing Date	2004-03-08	
INFORMATION DISCLOSURE	First Named Inventor	Colhoun	
STATEMENT BY APPLICANT (Not for submission under 37 CFR 1.99)	Art Unit	1794	
(NOCTOL SUDMISSION UNDER 37 OF K 1.33)	Examiner Name	Le, H	oa T.
	Attorney Docket Number		80097

				U.S.	PATENTS	Remove		
Examiner Initial*	Cite No					Pages,Columns,Lines where Relevant Passages or Relevant Figures Appear		
	1	5540868		1996-07-30	Stouffer et al.			
	2	6335422		2002-01-01	Schiavone			
	3	5474111		1995-12-12	Williamson et al.			
If you wis	h to a	dd additional U.S. Pater	t citatio	n information pl	lease click the Add button.	Add		
			U.S.P	ATENT APPLI	CATION PUBLICATIONS	Remove		
Examiner Initial*	Cite No	Publication Number	Kind Code <sup>1</sup>	Publication Date	Name of Patentee or Applicant of cited Document	Pages,Columns,Lines where Relevant Passages or Relevant Figures Appear		
	1	20050065318		2005-03-24	Jernigan et al.			
	2	20050154183		2005-07-14	Elkart et al.			
	3	20060046004		2006-03-02	Ekart et al.			

## 

	4	20060149026	2006-07-06		Jernigan et al.						
	5	20070135614	2007-06-14		Ekart et al.						
	6	20050196566		2005-09	H08	Colhoun et al.					
	7	20050215753		2005-09	1-29	Otto et al.					
If you wis	If you wish to add additional U.S. Published Application citation information please click the Add button. Add										
				FOREIG	GN PAT	ENT DOCUM	IENTS		Remove		
Examiner Initial*	Cite No	Foreign Document Number <sup>3</sup>	Country Code <sup>2</sup> j			Publication Date	Name of Patente Applicant of cited Document		Pages,Columns,Li where Relevant Passages or Relev Figures Appear	TA	
	1	0661326	EP		A2	1995-07-05	Harazoe et al.				
If you wis	h to a	dd additional Foreign P	atent Do	cument	citation	information pl	lease click the Add	buttor	Add		
			NON	I-PATE	NT LITE	RATURE DO	CUMENTS		Remove		
Examiner Cite Initials* No Universe Company (Company) (C							n Ts				
1 USPTO Office Action dated August 2, 2007 for copending application 11/454,271											
2 USPTO Office Action dated March 17, 2008 for copending application 11/454,271											

INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Not for submission under 37 CFR 1.99)

Application Number		10795783		
Filing Date		2004-03-08		
First Named Inventor	Colho	Colhoun		
Art Unit		1794		
Examiner Name	Le, Hoa T.			
Attorney Docket Numb	er	80097		

3	USPTO Office Action dated January 10, 2006 for copending application 11/018,357	
4	USPTO Office Action dated September 22, 2006 for copending application 11/018,357	
5	USPTO Office Action dated February 2, 2007 for copending application 11/018,357	
6	USPTO Office Action dated September 26, 2007 for copending application 11/018,357	
7	USPTO Office Action dated November 23, 2007 for copending application 11/018,357	
8	USPTO Office Action dated September 7, 2006 for copending application 11/018,119	
9	USPTO Office Action dated June 4, 2007 for copending application 11/018,119	
10	USPTO Office Action dated February 15, 2008 for copending application 11/018,119	

If you wish to add additional non-patent literature document citation information please click the Add button Add

citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

## EXAMINER SIGNATURE

Examinor Signature Date Considered

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through a

See Kind Codes of USPTO Patent Documents at were USPTO.GDV or MPEP 801.64. \* Enter office that asseed the document, by the two-leder code (WIPO Standard STS). \* For Japanese patent documents, the solication of the year of the region of the Engager must precede the serial number of the patent document. English the patent personal process and process are selected on the document under WIPO Standard STM (process). \* Applicate this patent are a reducted on the document under WIPO Standard STM (process). \* Applicate this patent personal process are document under WIPO Standard STM (process). \* Applicate this patent personal process are document under WIPO STM (process are document under WIPO STM).